



Application No. 10/736,007
Amendment filed: January 13, 2006
Reply to Office Action of August 18, 2005

Attorney's Docket No.: 004887.P760

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Christopher Laurent Beaudry

Application No.: 10/736,007

Filed: December 15, 2003

For: SINGLE WAFER CLEANING METHOD
TO REDUCE PARTICLE DEFECTS ON A
WAFER SURFACE

Examiner: Deo,Duy Vu Nguyen

Art Unit: 1765

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE

Dear Sir:

This is in response to the Office Action mailed August 18, 2005. Applicant respectfully requests the Examiner to consider the following remarks.

FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on

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